

United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.		
09/528,788	03/17/2000	Ruediger Paschotta	FREIP030US	FREIP030US 5723		
21121	7590 05/06/2004		EXAM	EXAMINER		
OPPEDAHL AND LARSON LLP			RODRIGUEZ,	RODRIGUEZ, ARMANDO		
P O BOX 506 DILLON, CO	8 D 80435-5068		ART UNIT	PAPER NUMBER		
			2828			

DATE MAILED: 05/06/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

		Applicati	on No	Applicant(s)			
. Office Action Summary		09/528,7		PASCHOTTA ET AL.			
		Examine		Art Unit			
			Rodriguez	2828			
-	The MAILING DATE of this communication				ddress		
Period fo	or Reply						
THE - Exte after - If the - If NO - Failu Any	ORTENED STATUTORY PERIOD FOR R MAILING DATE OF THIS COMMUNICATI nsions of time may be available under the provisions of 37 C SIX (6) MONTHS from the mailing date of this communicatic e period for reply specified above is less than thirty (30) days, p period for reply is specified above, the maximum statutory p re to reply within the set or extended period for reply will, by reply received by the Office later than three months after the ed patent term adjustment. See 37 CFR 1.704(b).	ON. FR 1.136(a). In no evon. , a reply within the state period will apply and w statute, cause the app	ent, however, may a reply be tin utory minimum of thirty (30) day ill expire SIX (6) MONTHS from lication to become ABANDONE	nely filed s will be considered time the mailing date of this 0 (35 U.S.C. § 133).			
Status							
1)⊠	Responsive to communication(s) filed on	09 February 20	04.				
3)□	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Dispositi	ion of Claims						
5)⊠ 6)⊠ 7)⊠	 Claim(s) 72-107 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. Claim(s) 88-91 and 102-107 is/are allowed. Claim(s) 72,73,76-85,87,92-96 and 98-101 is/are rejected. Claim(s) 74,75,86 and 97 is/are objected to. Claim(s) are subject to restriction and/or election requirement. 						
Applicati	on Papers						
9)[The specification is objected to by the Exa	miner.					
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.							
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
11)	Replacement drawing sheet(s) including the co The oath or declaration is objected to by the	•			•		
Priority u	ınder 35 U.S.C. § 119						
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 							
Attachmen	tie)						
	e of References Cited (PTO-892)		4) Interview Summary	(PTO-413)			
2) 🔲 Notic	e of Draftsperson's Patent Drawing Review (PTO-948		Paper No(s)/Mail Da	ite	0.450)		
	nation Disclosure Statement(s) (PTO-1449 or PTO/S r No(s)/Mail Date	B/08)	5) Notice of Informal P. 6) Other:	atent Application (PT	U-152)		

DETAILED ACTION

Response to Arguments

Applicant's arguments, see pages 10 and 11, filed February 9, 2004, with respect to the rejection(s)of claim(s) 72-107 under 35 USC 112 second paragraph and under 35 USC 103 have been fully considered and are persuasive. Therefore, the rejection has been withdrawn. However, upon further consideration, a new ground(s) of rejection is made in view of Alfano et al (PN 4,464,761).

Response to Amendment

The 35 USC 112 second paragraph of claims 72-107 has been withdrawn based on applicant's amendment filed on February 9, 2004.

Claims 1-71 have been canceled and claims 72-107 are pending.

Claim Rejections - 35 USC § 112

The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

Claims 78,79,99 and 100 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Claims 78,79,99,100 recite the limitation "said thin-disk gain medium" in line 2. There is insufficient antecedent basis for this limitation in the claim. Applicant has not defined the solid-state laser gain medium, as a thin-disk gain medium.

Therefore, the examiner will give the solid-state laser gain medium its broadest interpretation.

Claim Objections

Claim 81 is objected to under 37 CFR 1.75(c), as being of improper dependent form for failing to further limit the subject matter of a previous claim. Applicant is required to cancel the claim(s), or amend the claim(s) to place the claim(s) in proper dependent form, or rewrite the claim(s) in independent form. It is not clear if claim 81 incorporates the saturable absorber with the kerr lens mode locking.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 72,76,77,85,87,92,93,96,98,101 are rejected under 35 U.S.C. 102(b) as being anticipated by Alfano et al (PN 4,464,761).

Alfano et al describes a high intensity mode locked pulse laser system.

Regarding claims 72,76,92,93

Figure 5 illustrates a passive mode locked laser resonator having mirrors (39) and (45) forming the resonator disposed within the resonator is a laser gain medium (33) being pumped by source (35) at one end and being cooled by cooling system (49) at the other end; passive mode-locking is provided by saturable absorber (41) arranged within the resonator, thereby obtaining a laser system with high intensity short pulses as described in column 8 lines 3-28 and the abstract.

Regarding claim 77,98,

Application/Control Number: 09/528,788

Art Unit: 2828

The laser medium does support short pulses, as described in column 8 lines 3-28 and the abstract.

Regarding claim 85,96,

Column 7 lines 26-37, describes the pumping source as a laser.

Regarding claim 87,101,

The saturable absorber will provide Q-switching effects.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 72,73,78-84,92,94,95,99,100 are rejected under 35 U.S.C. 103(a) as being unpatentable over Weingarten et al (PN 5,987,049) in view of Stingl et al (PN 6,345,061).

Regarding claims 72,73,78,79,92

Weingarten et al illustrates in figure 4 a pulsed mode locked optical resonator having a laser gain medium (2) composed of Ti:sapphire, a semiconductor saturable absorber (11) within the resonator for passive mode locking.

Weingarten et al does not disclose a thin plate laser gain medium with cooling means.

Application/Control Number: 09/528,788

Art Unit: 2828

Stingl et al illustrates in figure 1 a short pulse laser system having a laser gain medium (4) composed of Ti:sapphire structured as a thin plate with a cooling body (10) as illustrated in figure 3 and described in column 6 lines 30-40.

Therefore, it would have been obvious to a person ordinary skill in the art at the time of the invention to modify the laser system of Weingarten et al with the laser gain medium of Stingl et al because it would provide an effective removal of heat from the gain medium thereby improving the output power of the pulse laser.

Regarding claim 80,

Saturable absorber (11) of Weingarten et al is a mirror type saturable absorber, column 4 lines 35-45.

Regarding claim 81,

Stingle provides Kerr lens mode-locking as described in column 5 lines 36-51.

Regarding claims 82,83,94

Figure 4 of Weingarten et al does illustrate a pair of prism (16,17) for dispersion compensation.

Regarding claim 84,95,99,100,

The repetition rate is obtain by design preferences, as suggested by Stingl et al in column 1 lines 17-33, where the repetition of the laser system is obtain in accordance with the length of the resonator, therefore Stingl et al has disclosed the general conditions to obtain a particular repetition rate, which would have been obvious to a person having ordinary skill in the art to design the resonator for providing a repetition

rate less 100MHz because Stingl et al has provided an example of obtaining a repetition rate of 75MHz.

Allowable Subject Matter

Claims 88-91 and 102-107 are allowed.

The following is an examiner's statement of reasons for allowance:

After reviewing applicant's amendment, arguments and conducting an updated search none of the cited prior arts alone or in combination discloses the claimed laser having the recited limitations of independent claims 88,102 and 106, where a frequency converted passively mode-locked high intensity output pulse is obtained.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Claims 74,75,86 and 97 would be allowable if rewritten to overcome the rejection(s) under 35 U.S.C. 112, second paragraph, set forth in this Office action and to include all of the limitations of the base claim and any intervening claims.

None of the prior arts alone or in combination provide a gain medium with a reflective end face as recited in claims 74 and 75 along with all recited limitations of the base and intervening claims.

None of the prior arts alone or in combination provide means for cavity dumping as recited in claims 86 and 97 along with all recited limitations of the base and intervening claims.

Art Unit: 2828

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Armando Rodriguez whose telephone number is 571-272-1952. The examiner can normally be reached on flex / M-F.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Don Wong can be reached on 571-272-1834. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Armando Rodriguez

Examiner Art Unit 2828

AR/DW

Don Wong Supervisor Art Unit 2828

Hoanganh Le
Primary Examiner